



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 5520**
Hiroki MAEDA et al. : Attorney Docket No. 2006_0043A
Serial No. 10/565,104 : Group Art Unit 1795
Filed January 19, 2006 : Examiner Anca Eoff
PHOTOSENSITIVE RESIN COMPOSITION : **Mail Stop: RCE**
AND METHOD OF FORMING A PATTERN
USING THE COMPOSITION

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO 23-0975

SUBMISSION UNDER 37 CFR 1.114

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated March 31, 2008, please amend the present application as follows: